

FORM PTO-1449

U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.
MICRON.278AAPPLICATION NO.
10/782,997INFORMATION DISCLOSURE STATEMENT
BY APPLICANT

(USE SEVERAL SHEETS IF NECESSARY)

APPLICANT
Smythe et al.FILING DATE
February 19, 2004GROUP
Unknown

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
CN	5,087,586	2/11/92	Chan et al.			
CN	5,447,884	9/5/95	Fahey et al.			
CN	5,492,858	2/20/96	Bose et al.			
CN	5,702,976	12/30/97	Schuegraf et al.			
CN	6,027,982	2/22/00	Peldous et al.			
CN	6,037,238	3/14/00	Chang et al.			
CN	6,518,148 B1	2/11/03	Cheng et al.			
CN	6,657,276 B1	12/2/03	Karlsson et al.			

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO

OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)
CN	Peters, Laura, "Choices and Challenges for Shallow Trench Isolation," <u>Semiconductor International</u> , Website www.ree-electronics.com , 6 pages, April 1, 1999.
	Advertisement entitled "Polyolefene CDE Spinfil™ 400 Series for STI/PMD Application."

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EXAMINER	/Christy Novacek/	DATE CONSIDERED	07/25/2006
*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.			